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| First Named Inventor | Leonard Forbes |
| Srial No. | 10/769,116 |
| Filing Date | January 30, 2004 |
| Group Art Unit | 2818 |
| Examiner Name | Unknown |
| Confirmation No. | 7177 |
| Attorney Docket No. | 400.261US01 |

GENERAL
TRANSMITTAL
FORM UNDER 37 CFR 1.8
(LARGE ENTITY)

Title: VERTICAL DEVICE 4F2 EEPROM MEMORY

Mail Stop: AMENDMENT Commissioner for Patents

P. O. Box 1450

Alexandria, VA 22313-1450

Enclosures

The following documents are enclosed:

X Information Disclosure Statement (1 pg.); Form 1449 (7 pgs.); 61 copies of cited references; U.S. reference(s) not included pursuant to 37 C.F.R. 1.98 (c)(2)(i);

X An itemized return-receipt postcard

Leffert Jay & Polglaze, P.A. P.O. Box 581009 Minneapolis, MN 55458-1009 T - 612/312-2200 F - 612/312-2250

Please charge any additional fees or credit any overpayments to Deposit Account No. 501373.

CUSTOMER NO. 27073

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| Name | Andrew C. Walseth | Reg. No. | 43,234 | Telephone | (612) 312-2207 | |
| Signature | Andre Cha | lath | | Date | 6/4/04 | |
| | Certificate of Mailing | | | | | |
| I certify that this correspondence and the identified documents listed on this transmittal are being deposited with the United States Postal Service with sufficient postage as first class mail in an envelope addressed to: Mail Stop: AMENDMENT, Commissioner for Patents, P. O. Box 1450, Alexandria, VA 22313-1450 on June | | | | | | |
| 2004. | | | | | | |
| Name | Rhonda L. Foley | Signa | ure | | tales | |

(LARGE ENTITY TRANSMITTAL UNDER 37 CFR § 1.8)

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| First Named Inventor | Leonard Forbes | |
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| Serial No. | 10/769,116 | INFORMATION |
| Filing Date | January 30, 2004 | DISCLOSURE |
| Group Art Unit | 2818 | STATEMENT |
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In compliance with 37 C.F.R. §§ 1.56 and 1.97, et seq., the enclosed materials are brought to the attention of the Examiner for consideration in connection with the above-identified Application. Pursuant to 37 C.F.R. 1.98 (a)(2)(i), as this application was filed after June 30, 2003, Applicant has not included copies of U.S. Patents or U.S. Patent Applications. Applicant respectfully requests that this Information Disclosure Statement be entered and the references listed on the attached Form 1449 be considered by the Examiner and made of record. Pursuant to MPEP §609, Applicant further requests that the Examiner initial next to each reference on the Form 1449 to indicate that the listed references have been considered. Applicant further requests that a copy of the initialed Form 1449 be returned with the next official communication.

As an Office Action has not yet issued in this application, Applicant believes that no fees are due. However, the Commissioner for Patents is hereby authorized to charge any additional fees to Deposit Account No. 501373.

If the Examiner has any questions or concerns regarding this application, please contact the undersigned at (612) 312-2207.

Respectfully submitted,

Date: 6/21/04

Andrew C. Walseth Reg. No. 43,234

Attorneys for Applicant Leffert Jay & Polglaze P.O. Box 581009 Minneapolis, MN 55458-1009 T 612 312-2200 F 612 312-2250



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INFORMATION DISCLOSURE STATEMENT FORM PTO-1449

Title: VERTICAL DEVICE 4F2 EEPROM Sheet 1 of 7 MEMORY

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| Title: VERTICAL DEVICE 4F2 EEPROM MEMORY | | Sheet 4 of 7 |

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| in conformance and not considered. Include copy of this form with next comm | unication to applic | ant. | | |
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| Group Art Unit | 2818 | STATEMENT |
| Examiner Name | Unknown | FORM PTO-1449 |
| Confirmation No. | 7177 | 1 |
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| Title: VERTICAL DEVICE 4F2 EEPROM MEMORY | | Sheet 7 of 7 |

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| Examiner | Date |
|---|------------|
| Signature | Considered |
| *Examiner: Initial if citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not | |